Semiconductor to metal transition in two-dimensional gold and its van der Waals heterostack with graphene

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The synthesis of transition metals in a two-dimensional (2D) fashion has attracted growing attention for both fundamental and application-oriented investigations, such as 2D magnetism, nanoplasmonics and non-linear optics. However, the large-area synthesis of this class of materials in a single-layer form poses non-trivial difficulties. Here we present the synthesis of a large-area 2D gold layer, stabilized in between silicon carbide and monolayer (ML) graphene. We show that the 2D-Au ML is a semiconductor with the valence band maximum 50 meV below the Fermi level. The graphene and gold layers are largely non-interacting, thereby defining a novel class of van der Waals heterostructure. The 2D-Au bands, exhibit a 225 meV spin-orbit splitting along the $\overline{\Gamma K}$ direction, making it appealing for spin-related applications. By tuning the amount of gold at the SiC/graphene interface, we induce a semiconductor to metal transition in the 2D-Au, which was never observed before and hosts great interest for fundamental physics.

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Lowering the dimensionality of a given compound has become a big hype in the field of material research, as this opens the possibility to explore and exploit properties which are inaccessible in a bulk crystal. While several compounds can be relatively easily rendered two-dimensional (2D) with physical approaches¹⁻¹³, many others are difficult to isolate. In particular, there are essentially no single-element materials other than graphite that can be easily exfoliated¹⁴. 2D metals see a vast field for applications, ranging from catalysis to sensing 15,16 , passing through enhanced magnetism $^{17-20}$. This enticing applicative potential has prompted the development of various approaches for the synthesis of low-dimensional metals¹⁵. Several chemistry-based strategies have been implemented, however mostly yielding nanostructures of different shapes and geometries¹⁵. Physical methods have been shown to effectively yield monolayers of transition metals, typically onto other metal surfaces $^{21-23}$. However, keeping the surface energy low enough to avoid the growth of multilayer islands is a non-trivial problem to address and often a capping medium solution must be adopted²⁴.

In all these conventional surface science studies, the main focus has been put in investigating the effects of the low dimensional metal on the substrate electronic properties, with the metal adlayer typically causing large spin-orbit splitting in the substrate band structure²³. However, the strong interaction between the metallic substrate and the 2D layer has hindered the possibility to access the intrinsic properties of the latter.

In this article, we shed a light onto the electronic

properties of two-dimensional gold (2D-Au), by synthesizing it via the intercalation of Au atoms at the heterointerface between the Si-terminated SiC(0001)surface and its C-rich $(6\sqrt{3}\times 6\sqrt{3})$ R30° reconstruction. Au atoms are arranged in a highly crystalline fashion and develop their own band dispersion, which is intrinsically two-dimensional. When a single layer of Au atoms is intercalated, a semiconductor (SC) crystal with the valence band maximum in \overline{K}_{Au} close to the Fermi level and a saddle point in \overline{M} at about 400 meV is formed. These 2D states also exhibit a significant spin-orbit splitting, amounting to 225 meV, along the $\overline{\Gamma K}$ dispersion direction. We show that the 2D semiconducting Au undergoes a transition to metal (M) when the number of intercalated Au layers goes from one to two. This is the first experimental report of a semiconductor-to-metal transition in a 2D transition-metal thus hosting great interest at a fundamental level.

Transition metal atoms have already been intercalated underneath the buffer layer graphene^{25–27} or zerolayer graphene (ZLG) on SiC(0001) as well as under epitaxial graphene on Ni(111)²⁸. The effects reported were doping of the graphene π -bands^{29,30} or mini-gaps opening in the graphene Dirac cone due to moiré superperiodicity³¹. It was recently shown that the interaction between the 5d orbitals of gold and the valence band of graphene can open a spin-orbit gap deep in the valence band of gold-intercalated graphene on SiC(0001)³². However, no evidence of two-dimensional dispersing bands stemming from the metal layer was ever reported, which would be indicative of a well-defined order of the film.

Figure1(a) and (b) displays the band structure of the SC 2D-Au, measured by angle-resolved photoemission spectroscopy (ARPES). Two spectral cuts are shown in Fig. 1(a), which give the dispersion along the high symmetry directions $\overline{\Gamma K}_{Au}\overline{M}_{Au}$ and $\overline{\Gamma M}_{Au}\overline{\Gamma}$. From $\overline{\Gamma}$ towards \overline{K}_{Au} , the dispersion has a band slope of 6 eVÅ at a binding energy of about -1 eV, i.e. comparable with graphene's band velocity in the vicinity of the Fermi level. From \overline{K}_{Au} towards \overline{M}_{Au} , the band is instead rather flat. At \overline{K}_{Au} we identify the maximum located at -50 meV. By performing a statistical analysis on the position of the valence band maximum (VBM) of 2D-Au for several samples, we find that the overall mean value falls just short of -70 meV (cf. sec. I of the supplementary information (SI)). The saddle point in \overline{M}_{Au} is found at -400 meV, meaning that the van Hove singularity (vHS) in the density of states is at an energy of interest for electronic measurements. No distinct crossing of the Fermi level is observed, in line with the missing Fermi surface contour in Fig. 1(c). We observe a faint triangularly shaped spectral weight at the Fermi level, due to the intrinsic width of the band. By connecting the vertexes of the aforementioned intensities, we define the Brillouin zone (BZ) of the SC 2D-Au, drawn as a blue hexagon in Fig. 1(c). Photon energy dependent ARPES measurements were performed to probe a possible crystallographic periodicity along the \hat{z} axis (see sec. II of the SI), and confirmed the two-dimensional nature of the gold layer. Furthermore, a high-resolution close-up of the bands along the $\overline{\Gamma K}$ direction shows that the states exhibit a spin-splitting which reaches the maximum value of 225 meV at -0.5 eV.

It should be mentioned that since the states observed in this energy range and in this k-space portion have no correspondence in any other graphene/SiC(0001) based system^{25,31,33} they can solely be attributed to the interfacial Au layer.

The gold atoms at the interface affect the electronic properties of graphene³⁰. A single gold layer act as an electron donor to graphene, shifting the π -bands down until the Dirac point E_0 is observed about 700 meV under the Fermi level, as visible from Fig.1(d), where we show an ARPES cut through graphene's \overline{K}_{Gr} point, taken perpendicular to the $\overline{\Gamma K}_{Gr}$ direction. In addition, the overall dielectric constant of the system is such that manyparticle effect emerge and can be detected. In particular, we extract an effective dielectric constant of $\epsilon_{eff} = 7 \pm 1$, which allow us to detect the plasmaron band³⁴. The crossing energy of the plasmaron band is indicated as E_1 and further details can be found in the sec. *III* of the SI.

The size and shape of the 2D-Au BZ suggest that the Au atoms are arranged on a triangular lattice with the lattice parameter matching that of SiC(0001), as it is depicted in the ball-and-stick model of Fig. 1(e). To further corroborate this hypothesis, we have observed with ARPES graphene replica bands shifted by a SiC(0001)

reciprocal lattice vector (cf. sec. IV in SI).

We compared the observed bands to a tight binding (TB) model calculated on this 2D triangular lattice in the nextnearest neighbor (NNN) approximation:

$$g(\vec{k}) = -\varepsilon_0 - \gamma_{01} u_1(\vec{k}) - \gamma_{02} u_2(\vec{k})$$
(1)

$$u_1(\vec{k}) = 2\cos(k_x a) + 4\cos(k_x a/2)\cos(k_y \sqrt{3}a/2)$$

$$u_2(\vec{k}) = 2\cos(k_y \sqrt{3}a) + 4\cos(k_y \sqrt{3}a/2)\cos(k_x 3a/2)$$

where *a* is the lattice parameter, γ_{01} and γ_{02} are the NN and NNN hopping parameters, the first being of the order of 1 eV and $\gamma_{02} \simeq \gamma_{01}/10$. For the plot of Fig. 1(a) and (b) we set $\gamma_{01} = 1.3$ eV and a = 3.08 Å, that is the SiC(0001) lattice parameter.

Apparently, even this simple model describes the measured band dispersion quite well. In particular, the extremes are placed at the same k, confirming the right choice of a. The validity of the model also confirms the 2D nature of the states. However, some small deviations are present, especially at \overline{M}_{Au} .

Density functional theory (DFT) calculations have been published for this system by Chuang *et al.*³⁵. These simulations show the formation of Au-interface related bands, similar to the ones observed in our experiment. There, it was presumed, that the structure of the interfacial Au is arranged such that every topmost Si atom of the SiC is bound to one Au atom, i.e. a (1×1) with respect to the SiC(0001). Similar to our experiment, their bands have the maximum in close proximity to the Fermi level, which indicates a semiconducting behavior. Moreover, in Ref.³⁶ the authors find a strong spinsplitting stemming from spin-orbit coupling. The spin texture there resembles a Rashba-type with a Rashba parameter of 1.638 eV/Å. In fact, we do find a strong correspondence to this in the experimental band structure (see Fig. 1(b)). Extracting the Rashba parameter from the experiments, we find a value of 2.17 eV/Å. which is in rather good agreement with theory.

In order to gather further information about the actual structure of the interfacial gold layer, we carried out high-resolution X-ray photo-emission spectroscopy (HRXPS), low-energy electron diffraction (LEED) and scanning tunneling microscopy (STM) measurements. Representative spectra of the Au 4f and Si 2p core levels are shown in Fig. 2(a) and (b), respectively. The details about the fitting parameters are reported in section V of the SI. The Au 4f doublet indicates the presence of atoms in a single chemical environment. The binding energy that we measure is $\sim 350 \text{ meV}$ higher than for metallic gold and this excludes the presence of a substantial amount of metallic gold either on the surface or underneath graphene. In contrast, it indicates that Au is bound to Si at the interface, as confirmed by the Si 2p spectrum, which shows a component of bulk SiC and a surface component of Au-Si. Symmetry considerations allow us to conclude that, since the bands we observe are of s - p character, the Au atoms must

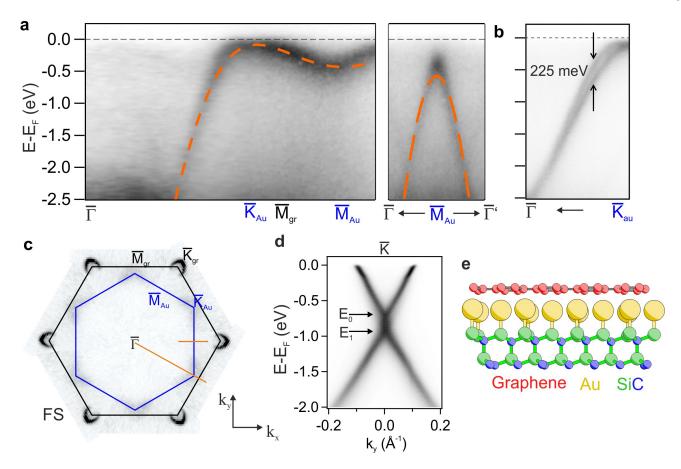


FIG. 1: Electronic properties of 2D Gold. (a) ARPES cut along the diagonal orange line in panel (d), showing only the Au bands dispersion. In the right panel the spectrum cuts along the short orange line in panel (d). The orange dashed lines superimposed to the data are the TB bands as described in the text. (b) Au bands dispersion along the k_y direction highlighting their spin-orbit splitting ΔSO . The photon energy for panels (a) and (b) is 95 eV. (c) Fermi surface of the system measured by ARPES. The figure is the result of the sixfold symmetrisation of a measurement. (d) Dispersion measured along k_y at the \overline{K}_{Gr} point with 40 eV photons, showing graphene's Dirac cone. (e) Ball-and-stick model of the gold atoms intercalated between graphene and SiC(0001).

interact with the 2p Si orbitals by their 5d electrons. It should be noted that this does not represent an alloyed silicide layer, which is also reported to have a different (higher) binding energy³⁷. What we observe is rather a significant electronic overlap between the topmost Si atoms of the substrate and the intercalated gold layer. The interaction with the substrate stabilizes the gold layer and induces the interfacial order. Notably, Au atoms deposited onto SiC(0001) are observed not to order on the $(1\times1)^{37,38}$, which implies the need for the graphene on top to impose the observed ordering and electronic structure.

From the previously reported HRXPS data, we find that every Au atom is bound to a Si atom at the interface (cf. SI), meaning that the Au is ordered in a (1×1) registry with respect to the SiC, as it was found for ARPES. The μ -LEED pattern of Fig. 2(c) shows that after the intercalation of Au atoms, only the graphene and SiC (1×1) are visible. In addition, a hexagonal halo oriented like graphene and 1/13 of its dimension is discernible, corroborating the proposed model. Atomically resolved STM carried out on such a sample, further confirms the atomic model. The STM image in Fig. 2(d) shows a region where the (13×13) superpotential is well visible and the graphene lattice is atomically resolved (see also sec. VI of the SI).

By extending the gold deposition time, it is possible to intercalate a double layer of gold (see Methods for more details). Going from a single Au layer to a Au bilayer does not only switch the doping of graphene from n+ to slightly p, but it also switches the character of the 2D-Au electronic properties. In fact, we observe a transition from SC to a M behavior.

Fig. 3 summarizes the electronic, chemical and structural properties of the M 2D-Au. In the first place, the graphene - shown in panel **a** - is marginally hole-doped with a density of states of $(9\pm1)\cdot10^{11}$ cm⁻², which, given a band velocity of $(1.33\pm0.05)\cdot10^6$ m/s, corresponds to a shift of the Fermi level by (-150 ± 10) meV with respect

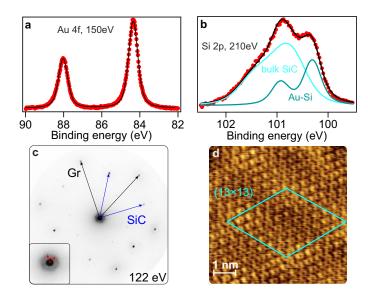


FIG. 2: Structural properties of the interface. Core level spectra acquired on a Au-intercalated monolayer of epitaxial graphene on SiC(0001) of (a) Au 4f fitted with a single Voigt doublet, (b) Si 2p fitted with two Voigt doublets. The photon energies are indicated in the panels. (c) μ LEED pattern recorded at 122 eV on Au-intercalated graphene. The inset highlights the (13×13) pattern observed around the (00) spot. (d) STM topography image over a (5.2×5.2) nm² region. The (13×13) moiré unit cell is indicated as a cyan diamond. Image recorded at U_{sample}=100 mV and I_{tunnel}=85 pA.

to the Dirac point. We as well observe the Rashba splitting at about -1 eV due to the interaction between the graphene and gold bands, as reported in Ref.³².

The interfacial gold still develops its own band dispersion, with a rich structure, as exemplary shown in Fig. 3(b), where we show an ARPES spectrum recorded at 75 eV and centered in $\overline{\Gamma}$ along k_y direction, with reference to Fig. 1(c). We indicate the states reaching the Fermi level with the orange dashed line and a solid circle. The spectral weight at $\overline{\Gamma}$ at the Fermi level represents the bottom of a conduction band of the M 2D Au and it is not related with the Shockley state of the Au(111) surface. It was predicted in previously published calculations³⁵, even if they considered three layers at the interface instead of two. Such a band structure implies that at any given small variation of the chemical potential, or applied external voltage, there will always be a finite electronic density of states, confirming the metallicity of this phase.

HRXPS measurements confirm the presence of a gold double layer, as does STM (see sec. VI in the SI). Fig.3(c) displays the Au 4f doublet fitted with two components. The ratio between the two is very close to one, indicating a symmetric distribution of the atoms between the first and the second layer.

Due to the favored interatomic forces, the intercalated gold bilayer shrinks its lattice parameter with respect to the monolayer. The gold atoms then arrange in a configuration closer to the bulk Au(111). This is illustrated by the μ -LEED data shown in Fig. 3(d). A hexagonal pattern around the (00) spot is well visible. That vector is 1/10 of the Au reciprocal lattice vector. Yet, even a denser grid is visible, as the line profile (enlarged to be better seen) in the bottom left part of the panel indicates. Such a grid emerges from the Au/SiC(0001) interface and it corresponds to Au atoms being arranged as (20×20) over (19×19) SiC unit cells. The corresponding lattice parameter for the gold M-phase is extracted from several different LEED, μ LEED, ARPES and STM measurements. The estimation of the lattice parameter is (2.93±0.01) Å, about 1.6% larger than the nominal 2.883 Å of the Au(111).

When such a gold bilayer interacts with graphene, it develops a superperiodicity half the size, which is observed in STM, as visible in the data reported in Fig. 4. The Gr/Au moiré is well identified in the topographical STM measurements of Fig. 4(a). The graphene lattice is very well resolved as well and the superlattice unit cell is drawn in the image as a blue diamond. In Fig. 4(b), the fast 2D Fourier transformation (2D-FFT) of the image (raw data in Fig. S7 of the SI) shows distinctively the graphene and superstructure periodicities and helps us conclude that $(7\sqrt{3}\times7\sqrt{3})$ R30 graphene unit cells are arranged on (10×10) of gold, which is the strongest superperiodicity observed also in LEED (cf. Fig. S8 in the SI). The proposed model for the atomic arrangement of graphene and M 2D Au is shown in Fig. 4(c). The region within the supercell where the C-Au distance is larger is circled in panel (a) and indicated as a yellow disc in panel (c). The difference in C-Au adsorption distance emerges from the local variation of the atomic registry between the lattices.

In summary, we presented the first experimental realization of a vdWH between a 2D semimetal and a 2D semiconductor, where the semiconductor is realized by synthesizing a single layer of gold at the heterointerface between graphene and 6H-SiC(0001). We have determined that the gold atoms arrange themselves in a highly ordered triangular lattice mimicking the $SiC(1 \times 1)$ and develop their own band structure. Such an electronic band dispersion has a truly two-dimensional character and it is notably well reproduced by a simple TB model. The transition of the 2D Au from SC to M is layer-dependent and it can be controlled by tuning the amount of intercalated gold. Single and double 2D Au layers have different electronic and structural properties and the graphene above is affected as well. The system therefore results in a double lateral junction: the graphene exhibit a p/n^+ junction, in correspondence to the M/SC transition region of the 2D Au, which represents a lateral Schottky contact. In addition, the system has a vHS at about 400 meV from the Fermi edge, making this system a very appealing platform for the observation of collective phenomena at low temperatures. The whole structure is monolithic and and does not require any transfer.

Besides the deep fundamental interest for a new class of

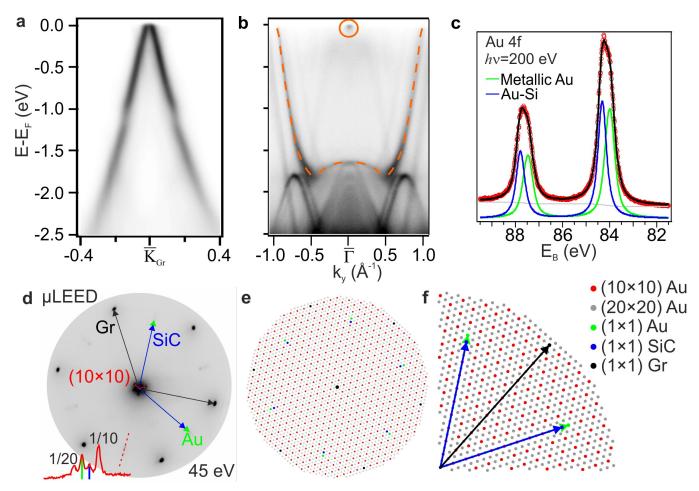


FIG. 3: **Properties of the** *p***-phase Au-intercalated graphene.** (a) ARPES spectrum of the graphene's Dirac cone measured along k_y , recorded with photons of 40 eV. (b) ARPES spectrum measured at 75 eV centered in $\overline{\Gamma}$, showing the band structure of the intercalated gold along the k_y direction. (c) μ XPS of the system of Au 4f doublet. (d) μ LEED pattern of the system. In the bottom-left corner the line profile along the red line is shown, highlighting the four diffraction spots visible and assigning them to SiC (blue), Au (green) and the 1/20 and 1/10 Au superperiodicities. (e) sketch of the μ LEED with all the periodicities indicated. (f) blow-up of one quadrant of panel (e).

materials, we envision a vast portfolio of possible applications for this system, ranging from detection of THz radiation, to more sophisticated optoelectronic devices involving the spin degree of freedom. It will moreover serve as a platform for exploring non-linear optics effects in two-dimensional gold. A field so far essentially unexplored.

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II. AUTHOR CONTRIBUTIONS

S.F. designed the experiments, grew the samples, performed ARPES, XPS and STM measurements, carried out the analysis of the data and wrote the manuscript.

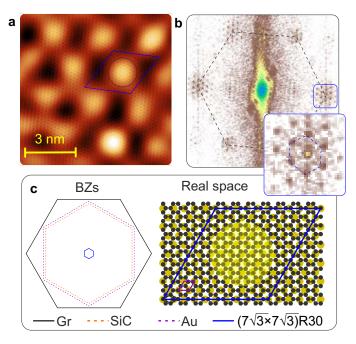


FIG. 4: (a) STM image 2D-FFT filtered U_{sample} =-105 mV I_{tunnel} =325 pA. (b) 2D-FFT of the real-space image in panel (a). In the inset: zoom-in with respect to the blue box in panel (b). (c) reciprocal and real-space arrangement between graphene and gold. All BZs are 90° rotated in order to match the alignment used for the ARPES description.

S.L. and A.S. helped with the measurements, the data analysis and the writing of the manuscript. Y.N. and A.Z. carried out LEEM/PEEM measurements. C.C. participated to and supervised the STM measurements. U.S. participated to the synchrotron measurements and co-designed the experiments. C.C and U.S. supervised the project. All authors edited and commented the manuscript.

III. METHODS

A. Sample preparation

Nominally on-axis oriented single crystalline singleside polished 6H-SiC *n*-type substrates were used in the present study and were purchased from SiCrystal GmbH. Polishing damages were removed by etching the substrate at 1500 °C in a purified H₂ atmosphere. The SiC(0001) surfaces were graphitized by annealing the samples in argon atmosphere following the procedure introduced by Emtsev *et al.* in Ref.³⁹. The buffer layer or zerolayer graphene (ZLG) develops upon annealing in Ar atmosphere at about 1400 °C for 10 minutes^{25,40–44}. The formation of the ZLG results in a carbon-rich reconstruction with periodicity $(6\sqrt{3} \times 6\sqrt{3})$ R30° with respect to the SiC(0001) unit cell^{26,27,45}. The samples were prepared by evaporating atomic Au from a Knudsen cell onto the ZLG surface, keeping the sample at temperatures be-

tween 600 and 700 $\,^{\circ}\mathrm{C}$ and by subsequent annealing of the sample at temperatures between 800 and 850 $^{\circ}$ C. Keeping the sample at that temperature should favor the intercalation process over the diffusion of Au atoms over the surface and the consequent formation of clusters. Au is known to have a very high mobility on graphene⁴⁶ so that deposition at room temperature followed by annealing leads to cluster formation³⁰. Preparing the samples in the way described here helps in keeping the surface more clean. The single layer gold is prepared in the aforementioned way by depositing a nominal amount of about 20 gold monolayers at a rate of 5 Å per minute. In this way the deposition takes about 10 minutes. For the gold bilayer a deposition time ranging from 20 to 25 minutes is used, employing the same rate. We point out that the intercalated samples are very stable in air ($\tau \gg$ months) and that they do not require any particular protection from the atmospheric environment. In UHV conditions, they can be heated up to 850 °C before the intercalated gold starts to be deintercalated and desorbed from the surface.

B. Measurements

The band structure of the system was mapped by means of angle-resolved photoemission spectroscopy (ARPES) at the end-station 1^2 of the BESSY II (Berlin, Germany) synchrotron facility at a temperature of 90 K. The hemispherical electron analyzer used for the data harvesting was a Scienta R8000 with a diameter of 200 mm and an ultimate energy resolution of 1 meV. In our experiments the instrumental resolution was set to about 2.5 meV, hence smaller than the thermal broadening of the bands, i.e. about 7.5 meV. Additional ARPES measurements have been carried out at the I4 end-station of the MAXlab (Lund, Sweden) synchrotron facility with a SPECS Phoibos 100 analyzer. The aforementioned lines have also been used to acquire highresolution X-ray photoelectron spectroscopy (HRXPS) data. Preliminary studies to clarify the preparation procedures and to assess the sample's quality were carried out in the home-laboratory at the MPI Stuttgart using a Specs Phoibos 150 analyzer and monochromatized He II radiation for the photoexcitation. Low-energy electron microscopy (LEEM) measurements, as well as micro-ARPES (μ ARPES), micro-LEED (μ LEED) and micro-XPS, were acquired at beamline I311 beamline of the Maxlab using an ElmitecIII microscope. More details about the performances of the microscope can be found elsewhere $2^{27,47}$. The scanning tunneling microscopy (STM) measurements were performed with an Omicron LT-STM microscope at the CNI@NEST in Pisa at a temperature of 78 K.

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- ¹ C. Berger, Z. Song, T. Li, X. Li, A. Y. Ogbazghi, R. Feng, Z. Dai, A. N. Marchenkov, E. H. Conrad, P. N. First & W. A. de Heer, "Ultrathin Epitaxial Graphite: 2D Electron Gas Properties and a Route toward Graphene-based Nanoelectronics", J. Phys. Chem. B 108, 19912 (2004).
- ² K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva & A. A. Firsov, "Electric Field Effect in Atomically Thin Carbon Films", *Science* **306**, 666 (2004).
- ³ A. Nagashima, N. Tejima, Y. Gamou, T. Kawai & C. Oshima, "Electronic Structure of Monolayer Hexagonal Boron Nitride Physisorbed on Metal Surfaces", *Phys. Rev. Lett.* **75**, 3918 (1995).
- ⁴ R. Lv, J. A. Robinson, R. E. Schaak, D. Sun, Y. Sun, T. E. Mallouk & M. Terrones, "Transition Metal Dichalcogenides and Beyond: Synthesis, Properties, and Applications of Single- and Few-Layer Nanosheets", Accounts of Chemical Research 48, 56–64, pMID: 25490673 (2015).
- ⁵ B. Lalmi, H. Oughaddou, H. Enriquez, A. Kara, S. Vizzini, B. Ealet & B. Aufray, "Epitaxial growth of a silicene sheet", *Applied Physics Letters* **97**, 223109 (2010).
- ⁶ M. E. Dávila, L. Xian, S. Cahangirov, A. Rubio & G. Le Lay, "Germanene: A novel two-dimensional germanium allotrope akin to graphene and silicene", *New J. Phys.* **16**, 095002 (2014).
- ⁷ P. Bampoulis, L. Zhang, A. Safaei, R. Van Gastel, B. Poelsema & H. J. W. Zandvliet, "Germanene termination of Ge₂Pt crystals on Ge(110)", *J. Phys. Condens. Mat.* **26**, 442001 (2014).
- ⁸ F. F. Zhu, W. J. Chen, Y. Xu, C. L. Gao, D. D. Guan, C. H. Liu, D. Qian, S. C. Zhang & J. F. Jia, "Epitaxial growth of two-dimensional stanene", *Nature Mater.* 14, 1020–1025 (2015).
- ⁹ J. Ji, X. Song, J. Liu, Z. Yan, C. Huo, S. Zhang, M. Su, L. Liao, W. Wang, Z. Ni, Y. Hao & H. Zeng, "Twodimensional antimonene single crystals grown by van der Waals epitaxy", *Nat. Commun.* 7, 1–9 (2016).
- ¹⁰ F. Reis, G. Li, L. Dudy, M. Bauernfeind, S. Glass, W. Hanke, R. Thomale, J. Schäfer & R. Claessen, "Bismuthene on a SiC substrate: A candidate for a hightemperature quantum spin Hall material", *Science* **357**, 287–290 (2017).
- ¹¹ L. Li, Y. Wang, S. Xie, X. B. Li, Y. Q. Wang, R. Wu, H. Sun, S. Zhang & H. J. Gao, "Two-dimensional transition metal honeycomb realized: Hf on Ir(111)", *Nano Lett.* 13, 4671–4674 (2013).
- ¹² H. Duan, N. Yan, R. Yu, C.-R. Chang, G. Zhou, H.-S. Hu, H. Rong, Z. Niu, J. Mao, H. Asakura, T. Tanaka, P. J. Dyson, J. Li & Y. Li, "Ultrathin rhodium nanosheets", *Nature Commun.* 5, 1–8 (2014).
- ¹³ J. Zhao, Q. Deng, A. Bachmatiuk, G. Sandeep, A. Popov, J. Eckert & M. H. Rummeli, "Free-Standing Single-Atom-Thick Iron Membranes Suspended in Graphene Pores", *Science* **343**, 1228–1232 (2014).
- ¹⁴ N. Mounet, M. Gibertini, P. Schwaller, D. Campi, A. Merkys, A. Marrazzo, T. Sohier, I. E. Castelli, A. Cepellotti, G. Pizzi & N. Marzari, "Two-dimensional materials from high-throughput computational exfoliation of experimentally known compounds", *Nature Nanotechnology* 13,

246-252 (2018).

- ¹⁵ Y. Chen, Z. Fan, Z. Zhang, W. Niu, C. Li, N. Yang, B. Chen & H. Zhang, "Two-Dimensional Metal Nanomaterials: Synthesis, Properties, and Applications", *Chemical Reviews* **118**, 6409–6455 (2018).
- ¹⁶ A. Sinibaldi, N. Danz, E. Descrovi, P. Munzert, U. Schulz, F. Sonntag, L. Dominici & F. Michelotti, "Direct comparison of the performance of Bloch surface wave and surface plasmon polariton sensors", *Sensors and Actuators*, B: Chemical **174**, 292–298 (2012).
- ¹⁷ A. J. Freeman & C. L. Fu, "Strongly enhanced 2D magnetism at surfaces and interfaces (invited)", *Journal of Applied Physics* **61**, 3356–3361 (1987).
- ¹⁸ Y. Yafet, J. Kwo & E. M. Gyorgy, "Dipole-dipole interactions and two-dimensional magnetism", *Physical Review B* 33, 6519–6522 (1986).
- ¹⁹ H. C. Siegmann, "Surface and 2D magnetism", Journal of Physics: Condensed Matter 4, 8395–8434 (1992).
- ²⁰ M. Gibertini, M. Koperski, A. F. Morpurgo & K. S. Novoselov, "Magnetic 2D materials and heterostructures", *Nature Nanotechnology* **14**, 408–419 (2019).
- ²¹ J. Jacobsen, L. Pleth Nielsen, F. Besenbacher, I. Stensgaard, E. Lægsgaard, T. Rasmussen, K. W. Jacobsen & J. K. Nørskov, "Atomic-Scale Determination of Misfit Dislocation Loops at Metal-Metal Interfaces", *Physical Review Letters* **75**, 489–492 (1995).
- ²² A. M. Shikin, A. Varykhalov, G. V. Prudnikova, D. Usachov, V. K. Adamchuk, Y. Yamada, J. D. Riley & O. Rader, "Origin of spin-orbit splitting for monolayers of Au and Ag on W(110) and Mo(110)", *Physical Review Letters* **100**, 1–4 (2008).
- ²³ A. M. Shikin, A. A. Rybkina, A. S. Korshunov, Y. B. Kudasov, N. V. Frolova, A. G. Rybkin, D. Marchenko, J. Sánchez-Barriga, A. Varykhalov & O. Rader, "Induced Rashba splitting of electronic states in monolayers of Au, Cu on a W(110) substrate", *New Journal of Physics* **15**, 095005 (2013).
- ²⁴ J. Lee, J. Yang, S. G. Kwon & T. Hyeon, "Nonclassical nucleation and growth of inorganic nanoparticles", *Nature Reviews Materials* 1, 16034 (2016).
- ²⁵ K. V. Emtsev, F. Speck, T. Seyller, L. Ley & J. D. Riley, "Interaction, growth, and ordering of epitaxial graphene on SiC{0001} surfaces: A comparative photoelectron spectroscopy study", *Phys. Rev. B* **77**, 155303 (2008).
- ²⁶ C. Riedl, C. Coletti & U. Starke, "Structural and electronic properties of epitaxial graphene on SiC(0001): a review of growth, characterization, transfer doping and hydrogen intercalation", J. Phys. D: Appl. Phys. 43, 374009 (2010).
- ²⁷ S. Forti & U. Starke, "Epitaxial graphene on SiC: from carrier density engineering to quasi-free standing graphene by atomic intercalation", J. Phys. D: Appl. Phys. 47, 094013 (2014).
- ²⁸ A. Varykhalov, J. Sánchez-Barriga, A. M. Shikin, C. Biswas, E. Vescovo, A. Rybkin, D. Marchenko & O. Rader, "Electronic and Magnetic Properties of Quasifreestanding Graphene on Ni", *Phys. Rev. Lett.* **101**, 157601 (2008).
- ²⁹ I. Gierz, C. Riedl, U. Starke, C. R. Ast & K. Kern, "Atomic Hole Doping of Graphene", *Nano Letters* 8, 4603 (2008).
- ³⁰ I. Gierz, T. Suzuki, R. T. Weitz, D. S. Lee, B. Krauss, C. Riedl, U. Starke, H. Höchst, J. H. Smet, C. R. Ast &

K. Kern, "Electronic decoupling of an epitaxial graphene monolayer by gold intercalation", *Phys. Rev. B* **81**, 235408 (2010).

- ³¹ S. Forti, A. Stöhr, A. A. Zakharov, C. Coletti, K. V. Emtsev & U. Starke, "Mini-Dirac cones in the band structure of a copper intercalated epitaxial graphene superlattice", *2D Mater.* **3**, 035003 (2016).
- ³² D. Marchenko, A. Varykhalov, J. Sánchez-Barriga, T. Seyller & O. Rader, "Rashba splitting of 100 meV in Au-intercalated graphene on SiC", *Applied Physics Letters* **108**, 172405 (2016).
- ³³ A. Bostwick, T. Ohta, T. Seyller, K. Horn & E. Rotenberg, "Quasiparticle dynamics in graphene", *Nat. Phys.* 3, 36 (2007).
- ³⁴ A. Bostwick, F. Speck, T. Seyller, K. Horn, M. Polini, R. Asgari, A. H. MacDonald & E. Rotenberg, "Observation of Plasmarons in Quasi-Freestanding Doped Graphene", *Science* **328**, 999 (2010).
- ³⁵ F.-C. Chuang, W.-H. Lin, Z.-Q. Huang, C.-H. Hsu, C.-C. Kuo, V. Ozolins & V. Yeh, "Electronic structures of an epitaxial graphene monolayer on SiC(0001) after gold intercalation: a first-principles study", *Nanotechnology* **22**, 275704 (2011).
- ³⁶ C. H. Hsu, W. H. Lin, V. Ozolins & F. C. Chuang, "Electronic structures of an epitaxial graphene monolayer on SiC(0001) after metal intercalation (metal = Al, Ag, Au, Pt, and Pd): A first-principles study", Applied Physics Letters 100, 063115 (2012).
- ³⁷ C. Virojanadara & L. I. Johansson, "Electronic structure of reconstructed Au-SiC(0001) surfaces", *Surf. Science* **600**, 436 (2006).
- ³⁸ D. Stoltz, S. E. Stoltz & L. S. O. Johansson, "A highresolution core-level photoemission study of the Au/4H-SiC(0001)- $(\sqrt{3} \times \sqrt{3})$ interface", *J. of Phys.: Cond. Matt.* **19**, 266006 (2007).
- ³⁹ K. V. Emtsev, A. Bostwick, K. Horn, J. Jobst, G. L. Kellog, L. Ley, J. McChesney, T. Ohta, S. A. Reshanov,

J. Röhrl, E. Rotenberg, A. Schmid, D. Waldmann, H. B. Weber & T. Seyller, "Towards wafer-size graphene layers by atmospheric pressure graphitization of silicon carbide", *Nature Mat.* **8**, 203 (2009).

- ⁴⁰ A. J. van Bommel, J. E. Crombeen & A. van Tooren, "LEED and Auger electron observations of the SiC(0001) surface", *Surf. Sci.* 48, 463 (1975).
- ⁴¹ I. Forbeaux, J.-M. Themlin & J.-M. Debever, "Heteroepitaxial graphite on 6H SiC(0001): Interface formation through conduction-band electronic structure", *Phys. Rev. B* 58, 16396 (1998).
- ⁴² A. Mattausch & O. Pankratov, "Ab Initio Study of Graphene on SiC", Phys. Rev. Lett. **99**, 076802 (2007).
- ⁴³ F. Varchon, R. Feng, J. Hass, X. Li, B. N. Nguyen, C. Naud, P. Mallet, J.-Y. Veuillen, C. Berger, E. H. Conrad & L. Magaud, "Electronic Structure of Epitaxial Graphene Layers on SiC: Effect of the Substrate", *Phys. Rev. Lett.* **99**, 126805 (2007).
- ⁴⁴ C. Riedl, U. Starke, J. Bernhardt, M. Franke & K. Heinz, "Structural properties of the graphene-SiC(0001) interface as a key for the preparation of homogeneous large-terrace graphene surfaces", *Phys. Rev. B* **76**, 245406 (2007).
- ⁴⁵ U. Starke, S. Forti, K. Emtsev & C. Coletti, "Engineering the electronic structure of epitaxial graphene by transfer doping and atomic intercalation", *MRS Bulletin* **37**, 1177 (2012).
- ⁴⁶ X. Liu, C.-Z. Wang, M. Hupalo, H.-Q. Lin, K.-M. Ho & M. Tringides, "Metals on Graphene: Interactions, Growth Morphology, and Thermal Stability", *Crystals* 3, 79–111 (2013).
- ⁴⁷ S. Forti, K. V. Emtsev, C. Coletti, A. A. Zakharov, C. Riedl & U. Starke, "Large-area homogeneous quasifree standing epitaxial graphene on SiC(0001): Electronic and structural characterization", *Phys. Rev. B* 84, 125449 (2011).

Supplementary information for:

Semiconductor to metal transition in two-dimensional gold and its van der Waals heterostack with graphene

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I. STATISTICAL ANALYSIS OF THE 2D ML AU SEMICONDUCTING CHAR-ACTER

In order to present a robust and statistically solid set of measurements for proving the actual semiconductor character of the single-layer 2D gold, we carried out a systematic analysis of all our ARPES measurements, done on several gold-intercalated graphene samples, at different photon energies and at different synchrotron facilities. Such an extensive analysis allows us to present strong and consistent evidence of the semiconducting behavior of the 2D gold layer. The result of such analysis is reported in Fig. S1. In panel (a), we show an exemplary ARPES measurement cutting through both the K points of graphene and 2D gold (cf. green line in the inset). In panel (b), we report the energy distribution curves (EDCs) through the gray dashed lines at graphenes pi bands and at the \overline{K}_{Au} point. The two profiles, i.e. the Fermi edge and the position of the gold valence band maximum (VBM), are fitted with a sigmoidal curve and the fit result is plotted as two vertical dashed lines on the graph. The same procedure was applied for every sample measured and the overall result is reported in the lower part of the figure, where the shaded region represents the error associated with the extracted value. The x axis of panel (c) shows the names of the samples measured, the photon energy and the facility at which they have been measured. The mean value extracted from this statistics is 67 meV, i.e. the energy distance from the 2D-Au VBM and the Fermi level.

II. TWO-DIMENSIONALITY OF AU STATES

For completeness of what is reported in the main text, in Fig. S2(a) we show the TB bands calculated in the NNN approximation on a 2D triangular lattice. In panel (a), on the right side we show the density of states (DOS) derived from the TB model. The 2D-Au exhibits a Van Hove singularity at its \overline{M} point, which is located just about 400 meV from the Fermi level. This means that this system has an instability point which is at an energy reachable by electrical gating. To prove the two-dimensionality of the gold bands, we show highresolution ARPES data, collected with different photon energies to measure the dispersion of the k-vector along the z direction in reciprocal space. In panel (b) we show an exemplary of ARPES spectrum acquired along the Au $\overline{K\Gamma K'}$ direction and centered in $\overline{\Gamma}$ with photon

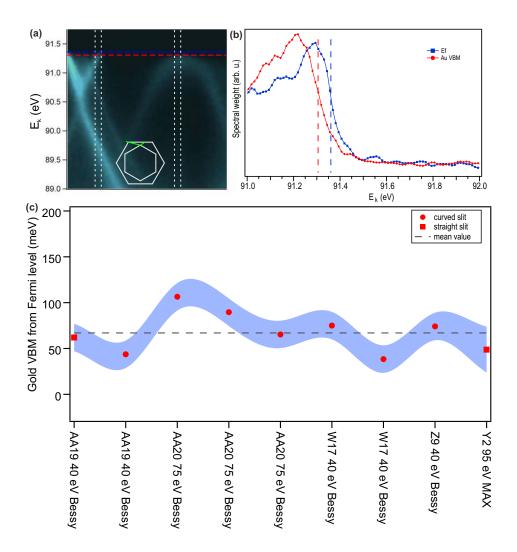


FIG. S1: (a) ARPES cut along the green line in the inset, showing both the \overline{K}_{Gr} and \overline{K}_{Au} points. The horizontal lines account for the energy level as extracted by the sigmoidal fit of the profiles in panel (b). (b) Profiles taken along the vertical grey-dashed lines in panel (a). (c) distribution of the energy difference between the gold VBM and the Fermi level for different samples.

energy 75 eV. The spectral weight visible in the vicinity of $\overline{\Gamma}$ is due to gold replica bands as it will be further explained in sec. IV. The spectral weight at binding energy 1.7 eV, as traced by the dashed line in the panel, was extracted for every energy from 30 to 100 eV with energy step 5 eV and plotted as shown in panel (c), following the relation that binds the k_z vector to the kinetik energy and the emission angle: $k_z = \sqrt{\frac{2m}{\hbar}}\sqrt{E_{kin}\cos^2(\theta) + V_0}$, where V_0 is the *inner potential* and θ the photoemission angle. We chose $V_0 = 14.5$ eV, according to Refs.^{1,2} and considering the difference in the valence band minimum between gold and graphene as extracted from the TB calculations. The absence of dispersion in the direction perpendicular

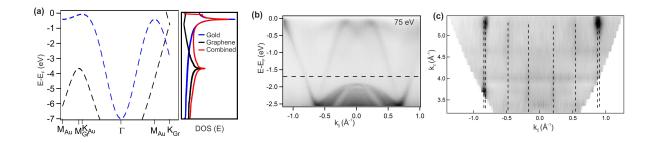


FIG. S2: (a) NNN-TB bands of gold (blue-dashed) and graphene (black-dashed). In the right panel, the DOS of gold (blue), graphene (black) and the sum of the two (red) is shown in the same energy range. (b) ARPES spectrum acquired at 75 eV along the gold $\overline{\text{K}\Gamma\text{K}}$ direction. (c) k_z dispersion obtained by extracting the spectral weight of spectra similar to the one in panel (a) at 1.7 eV (see dashed line), recorded at photon energies from 30 to 100 eV with 5 eV of energy step.

to the surface of the k-vector indicates the actual two-dimensionality of the interfacial gold layer. The spectral weight visible towards the Fermi level in $\overline{\Gamma}$ is ascribed to gold replica bands, due to electron diffraction at the surface. The scattering vector corresponds to the reciprocal lattice vector of graphene, hence rotated by 30 degrees with respect to the gold BZ alignment (see also sec. IV).

III. THE ELECTRONIC PROPERTIES OF GRAPHENE OVER A SINGLE LAYER OF GOLD

The effects of gold intercalation over the decoupled monolayer graphene on SiC(0001) have been already discussed in the past literature^{3,4}. Nevertheless, in this section we point out what are the effects of a very careful preparation on the properties of the intercalated graphene.

The very careful preparation of the samples via the intercalation of precisely one Au monolayer with respect to the SiC(0001) atomic areal density, translates in a very clean ARPES signal and allows for the extraction of band parameters from the data. Fig. S3(a) shows the ARPES spectrum of the Dirac cone acquired along $\overline{\Gamma K}_{Gr}$ at 40 eV. The measured bands are accompained by the fitting of the positions of the maxima of the energy dispersion curves, shown as green and red circles superimposed to the raw data. Two distinct dispersing states are fitted, as it is apparent from the figure. This effect has been reported for the first time in

graphene by Bostwick and coworkers⁵. What is visible below the Dirac point is the energy dispersion of the *plasmaron* quasiparticle⁶, i.e. a photohole that is coupled to a plasmon with similar group velocity. According to Ref.⁴, by measuring the energy and momentum separation of the hole and plasmaron bands, one can estimate the effective dielectric constant of the investigated sample. We determined the energy and momentum spread of the diamond formed by the crossing of the hole and the plasmaron dispersions (cf. Fig. S4(a)). This is done in Fig. S3(b) and (c), where the energy (b) and momentum (c) distribution curves of the Dirac cone are fitted with two Voigt functions, colored in gray. The two band traces are about 253 meV (b) and 0.02 \AA^{-1} (c) apart from each other and the Dirac energy of the system is defined as E_0 and located (685±5) meV below the Fermi level (cf. Fig. S4). To give an estimation of the effective coupling constant and effective dielectric constant, we compare our results with the work of Ref. 4. However, we point out that the normalization of the diamond width in momentum space with respect to the Fermi momentum k_F is somewhat inconsistent since for such high doping level, the Dirac cone is strongly warped (see Fig. S4(b) and (c)). We therefore rely on the separation of the cones in energy. In this way, the α_{ee} , or graphene fine constant is found to be $\alpha_{ee} = 0.30 \pm 0.02$, which is translated into an effective dielectric constant $\epsilon_{eff} = 7 \pm 1$, meaning a substrate dielectric constant of $\epsilon_s = 2 * \epsilon_{eff} - 1 = 13 \pm 2.$

Such a small effective dielectric constant enhances the e-e coupling and makes collective phenomena such as plasmarons observable.

In their paper⁴, Walter and coworkers reported a dielectric constant value about five times higher. This is simply because they started from a p-type Au intercalated graphene, which is induced by twice the amount of gold at the interface (cf. Fig. 3(c)), and counter n-doped it with K atoms in order to set the Fermi level of the system well above the Dirac point and thereby observe the plasmaron band.

For completeness, we also extract the band parameters from the measured ARPES. To do this, we analyze the ARPES data of the graphene Dirac cone measured at 40 eV, as displayed in Fig. S4. In panel (a) we show the ARPES spectrum of the *n*-doped Dirac cone as in Fig. 1 of the main text, with the addition of dashed lines to distinguish between the hole (green) and plasmaron (red) dispersions. Panel (b) displays the Fermi surface, whereas panel (c) shows the amplitude of the Fermi vector as a function of the angle as centered in \overline{K} , highlighting the threefold symmetry of the Fermi surface and the dark corridor⁷, where

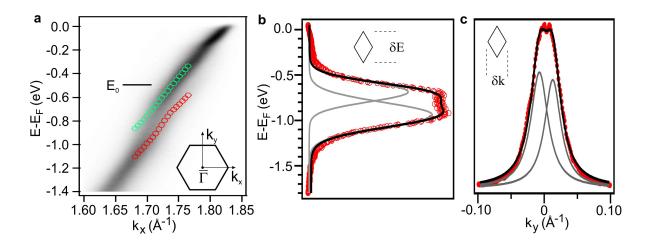


FIG. S3: **Observed plasmarons in graphene.** (a) ARPES spectrum at 40 eV of the Dirac cone along the k_x direction of a Au-intercalated epitaxial graphene, *n*-phase. The empty circles are fits of the peak position of the energy distribution curves. (b) and (c) line profiles of the plasmaron diamond, from which to extract the value of dielectric constant. See also Fig. S4.

the intensity vanishes. This supports the argumentation promulgated in the main text, that considers unreliable the extraction of the dielectric constant value by measuring the distance in k-space between the hole and plasmaron dispersion, normalized for the Fermi vector. Such a normalization procedure is clearly direction-dependent, instead of the energy difference between the two dispersions, which is not, and it is therefore more reliable. We extracted the band parameters by fitting the momentum dispersion curves (MDCs) with Lorentzian lineshapes. Fig. S4(d) shows the full width at half maximum (FWHM) of the bands and their slope $\partial E/\partial k$, in the energy range displayed in panel (a). Panel (e) shows the imaginary component of the self energy and the photohole lifetime, which depend on the FWHM through the relation: $\Sigma'' = (\delta k/2)(\hbar v_F)$ and $\tau = 1/(v_F \delta k)$, where δk is the FWHM and v_F the Fermi velocity. The self energy is a particularly sensitive quantity for measuring the interactions between quasiparticles. Indeed, a strong peak is visible in proximity of the Dirac point, corresponding to the photohole relaxation through the emission of a plasmon. The other two less pronounced peaks are ascribed to the interaction between graphene and gold bands, although in the dispersion no actual gap is observed. The first low-energy kink in the spectrum is due instead to quasiparticle relaxation via phonon emission. Fig. S4(f)displays the scanning tunneling spectroscopy (STS) spectrum of the semiconducting Au phase intercalated in between graphene and SiC(0001), acquired at 78 K. The Dirac point

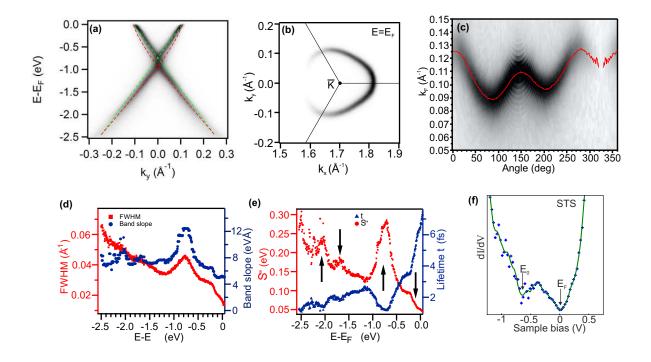


FIG. S4: (a) ARPES spectrum of the graphene's Dirac cone measured perpendicular to the $\overline{\Gamma K}_{Gr}$ direction at 40 eV. Photohole and plasmaron dispersion are superimposed to guide the eye. (b) Fermi surface of graphene. (c) Angular dependence of the Fermi momentum. (d) FWHM and band slope of the Dirac cone extracted along the $\overline{\Gamma K}_{Gr}$ direction at 40 eV. (e) Imaginary part of the self energy and quasiparticle lifetime extracted from the FWHM (see text). (f) Scanning tunneling spectroscopy of Gr/SC Au/SiC(0001) acquired at 78 K. E_0 is the Dirac energy, as defined in the main text.

is observed at around -625 meV, in line with the ARPES measurements.

IV. INTERFACIAL ATOMIC ORDERING DERIVED FROM PERIODICITY OF ARPES REPLICA BANDS

In this section we show the final state effects caused by the diffraction of photoemitted electrons as they exit the material.

In Fig. S5(a) a portion of the k-space is shown, recorded with ARPES at 40 eV centered in $\overline{\Gamma}$. At this binding energy, no intensity should be observable. However, some spectral weight clearly appears. Four Dirac cone profiles are distinguishable and correspond to graphene replica bands. Those replicas are induced by a reciprocal lattice vector with module and

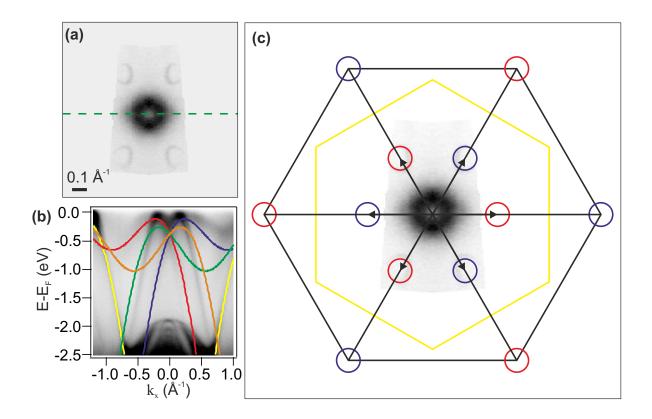


FIG. S5: (a) ARPES constant energy surface close to the Fermi level measured about $\overline{\Gamma}$ at 40 eV. (b) Model for the SC gold replica bands, imposing the graphene reciprocal lattice vector as generator. (c) Model for the graphene replica bands using a SC Au reciprocal lattice vector as generator.

orientation corresponding to the SiC(0001) surface vector. They are therefore generated by the gold atoms arranged on the SiC (1×1), as shown in panel (c). The intensity around $\overline{\Gamma}$ is due to gold replica bands. In this case the generator vector is the reciprocal lattice vector of graphene. In panel (b) we show an ARPES spectrum recorded at 75 eV along the gold $\overline{K\Gamma K'}$ direction with superimposed the theoretical gold SC bands derived from TB (in yellow) and displaced by a graphene reciprocal lattice vector (other colors). The matching is quite remarkable, confirming the proposed model and also justifying the residual intensity visible in the k_z vs. E plot in Fig. S2(c).

V. DETAILS ABOUT HRXPS DATA FITTING

In this section we report the details about the fitting for the HRXPS data, as shown in Fig. 2 of the main text.

The Au 4f spectrum of the 2D SC phase can be well fitted with a single Voigt doublet lineshape (cf. Fig. 2(a)). The Si 2p spectrum instead, needs a double Voigt doublet function (cf. Fig. 2(b)). For the Au 4f, spin splitting was set to 3.68 eV and the branching ratio was 0.75. Standard constraints were set for the Si 2p fit, such as spin splitting of 0.63 eV and branching ratio of 0.5 for the single doublets. Within the respective doublets, both components were set to the same Lorentzian and Gaussian widths. The resulting fitting parameters can be found in Tab. I. The small Lorentzian and Gaussian widths for the

	$E_{\rm B}~({\rm eV})$	$\omega_{\rm L}~({\rm eV})$	$\omega_{\rm G}~({\rm eV})$	ratio (%)
Au $4f_{7/2}$	84.35	0.15	0.20	
Si $2p_{3/2}$, bulk SiC	100.78	0.12	0.32	68
Si $2p_{3/2}$, Au-Si	100.31	0.12	0.13	32

TABLE I: Fit parameters of the Si $2p_{3/2}$ and the Au $4f_{7/2}$ components of the n-phase Au intercalated ZLG. The binding energies of the respective doublet partners are given by the spin splitting mentioned in the text, which was set as a constrain for the fit.

Au 4f levels is indicative for the presence of only one chemical species of Au. The $4f_{7/2}$ component's binding energy of 84.35 eV is shifted by about 350 meV towards higher binding energy compared to metallic Au. This means firstly, that one can exclude the presence of Au clusters on the sample surface, like observed earlier³. Also, all Au atoms within the interface have the same chemical environment. Judging from the two very distinct chemical components in the Si 2p spectrum, it is reasonable to assume that these Au atoms are chemically bound to the topmost Si of the SiC(0001) surface. All components of the Si 2p spectrum show a Lorentzian broadening of 0.12 eV, which can be viewed standard for this core level. The Gaussian width is 0.32 eV in the 100.78 eV binding energy doublet and 0.13 eV in the 100.31 eV doublet (both binding energies denote to the $2p_{3/2}$ components). A Gaussian broadening of 0.32 eV is generally observed for bulk SiC even if the experimental resolution is much better. However, the Gaussian width of Si 2p spectra can be much smaller in other materials, as it is the case for instance in the (7×7) -reconstruction of the Si(111) surface⁸. This peculiar broadness within the SiC system is not understood up until now, yet it can be seen as characteristic for bulk SiC. It is therefore reasonable to assign the narrower component to Si, which is bound to Au on the surface of the SiC. Au adsorbed on

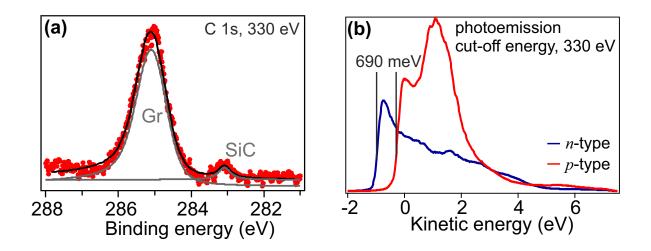


FIG. S6: (a) μ XPS spectrum of C 1s recorded on Gr/SC 2D Au/SiC(0001) at 330 eV. (b) Photoemission cut-off spectra recorded on Gr/Au/SiC(0001) regions where the graphene was n and p doped.

the (0001) surface of 4H-SiC have been investigated by Stoltz and coworkers⁹. They report a Si 2p component distribution, which is similar to our case, but with slightly different binding energies. There, they also assign the higher binding energy component to Si in the bulk of the SiC and the lower binding energy component to Si, which is bound to Au on the surface. The differences in binding energy can be caused by the different SiC polytype used here (6H-SiC) and by them (4H-SiC). Also the additional graphene layer on top in our case has influence on the band alignment and accompanied surface band bending in the SiC^{10,11}, which alters the observed binding energies.

It should be noted, that one can compare the intensity ratio of the signal produced by the two chemical Si species to other intercalation systems based on graphene on SiC(0001). The intensity ratio from Si in the bulk SiC and Si bound to Au is 68:32. In the case of H intercalation, the intensity ratio of Si in the bulk SiC to Si bound to H is 63:37 and 67:33 for photon energies 140 eV and 330 eV, respectively¹². In this case, every Si atom on the surface of the SiC is bound to one H. Keeping in mind that the photon energy in the measurements presented here is 210 eV, it is reasonable to assume that also in the Au case here all Si atoms on the surface are bound to Au.

The decoupling of the graphene is well illustrated by the C 1s core level peak in Fig. S6(a). The SiC peak binding energy is measured at about 283 eV, as observed in other intercalated systems^{13–15}. The graphene peak is here fitted with a single Doniach-Ŝunjić (DS) centered

at 285 eV with a gaussian width of 0.45 eV, which takes into account the different chemical environments present inside the supercell^{15,16}. The binding energy of the sp² carbon peak is increased by about 600 meV from the nominal peak position of 284.4 eV. Such a shift is mostly due to the *n*-type doping of about $n \sim 0.035$ electrons per graphene unit cell¹⁷. In turn, we observe this doping being accompanied by a decrease of work function. Being a 2D material, whenever the bands are rigidly moved up or down with respect to the Fermi level, a corresponding change in the work function must occur. This is actually observed and measured through the cut-off energy of the photoemitted electrons, displayed in Fig. S6(b). We look at the low-kinetic energy part of the photoemission spectrum until we reach the edge where no electron is extracted from the material. In this way we can easily measure the difference in work function between regions which are *n* and *p* doped (corresponding to semiconducting and metallic gold phases, respectively). We measure an energy difference of (690±5) meV. Considering that the *p*-phase is almost neutral (cf. Fig. 3 in the main text), such a measure shows very well how tightly related the charge transfer and the variation of work function are in 2D materials.

VI. STM MEASUREMENTS

In this section, we show scanning tunneling microscopy (STM) measurements of the goldintercalated graphene in its SC and M phase. Fig. S7(a) shows a sample's region where the transition between the SC and M gold region is visible. The SC (M) region is shown zoomedin in panel b (e), whereas the FFT-filtered and 2D-FFT of the zoomed-in region are shown in panel c and d (f and g), respectively. The superstructure on the M region is so large and strong that it can be seen even on the large-scale image. The corrugation of the M region pattern is indeed of the order of 200 pm, as visible also in the line profile of panel (h) (cf. also Fig. S8), while on the SC phase is about 25 pm. As visible from panel (e) and Fig. S8, the superstructure stemming from the M region has a periodicity of $(7\sqrt{3} \times 7\sqrt{3})$ R30 graphene unit cells over (10×10) gold, as also confirmed by μ LEED measurements (see discussion in the main text). The height difference of about 3.5 Å observed between the two regions supports a model where only two gold layers are intercalated in the M phase.

The 2D fast Fourier transformed (FFT) image FFT pattern in Fig. S9(a) clearly shows

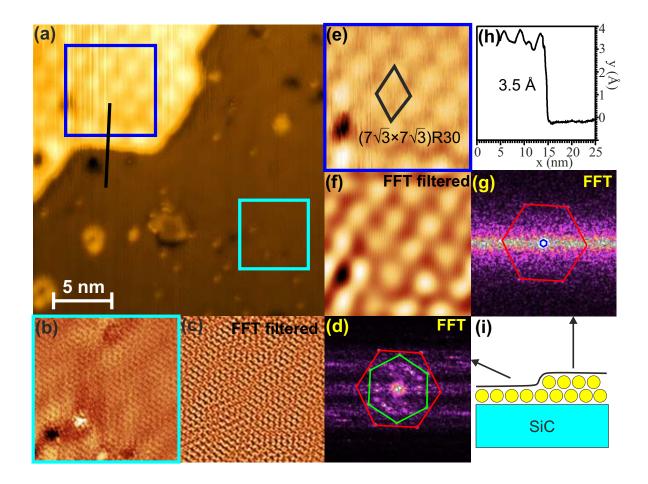


FIG. S7: (a) STM topography of a SC/M transition region. Au-intercalated graphene recorded with 400 pA of constant tunnel current and -250 mV of tip voltage. Panels (b,c,d) and (e,f,g) show a zoomed-in portion of the scanned area corresponding to the frames on panel (a), the FFT filtered image of the same region and the 2D-FFT of the image of the SC and M regions, respectively. Panel (h) shows the black line profile across the transition region between the SC and the M regions in panel (a). (i) simple sketch of the system.

the graphene and gold reciprocal lattice spots, indicated with a black and red hexagon, respectively. Other spots are also visible and they belong to the (13×13) grid, as explained in panel (b), where the top-left quadrant of the theoretical LEED pattern up to the graphene's first diffraction order is shown. The blue circle in panel (a) encloses three spots, two of which are visible along every direction. The third and innermost spot is less visible in the FFT. As illustrated in panel (b), those spots are the (7,-1)/13, (6,1)/13 and 5/13 reflexes of the (13×13) pattern. The same spots are measured as well by μ LEED, as we prove by showing in panel (c) a portion of Fig. 2(c) with enhanced contrast. We briefly point

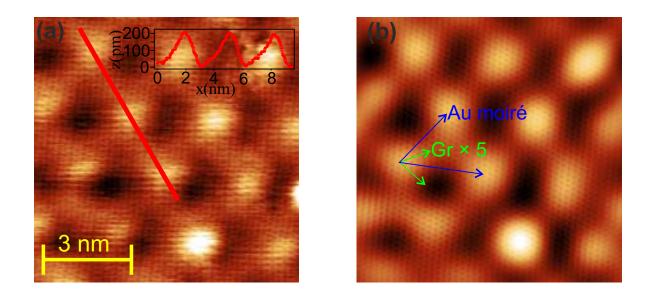


FIG. S8: **M-phase superstructure measure with STM.** (a) Raw topographical data. In the top-right inset, the line profile over the red line is shown. (b) 2D-FFT filtered image with indicated the lattice vectors of the superperiodicity and of graphene, the length of which has been increased by a factor 5.

out that the (13×13) is a rather natural periodicity for the graphene on SiC system and it is often observed, also for other intercalated systems¹⁵. In Ref.¹⁸, for example, they have observed several different superperiodicities induced by the intercalated gold. Even the (13×13) , but in that case, the gold was aligned with the graphene and it had a different lattice constant. A configuration very similar to what has been observed for the copperintercalated graphene^{15,19}.

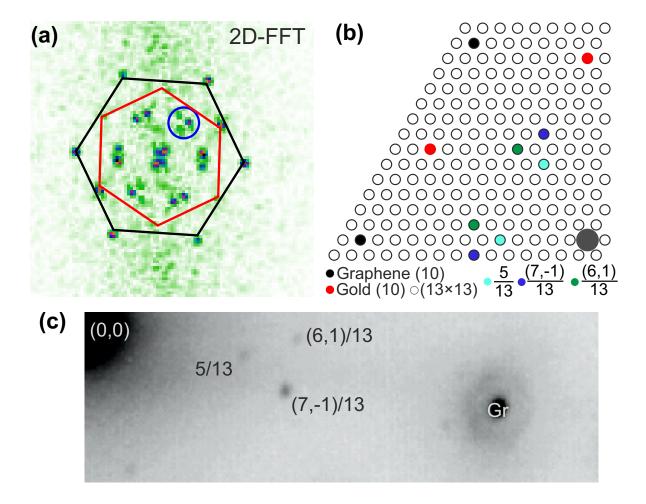


FIG. S9: (a) 2D-FFT of SC Au phase, retrieved from Fig. 2(d). Graphene and gold reciprocal lattice spots are indicated by a black and red hexagon, respectively. The spots stemming from the (13×13) periodicity are circled in blue. (b) Theoretical reciprocal lattice grid of the (13×13) , representing the kinematic LEED pattern in the first quadrant. Highlighted are the spots visible in panel (a). (c) portion of Fig. 2(c) from the main text with enhanced contrast, to highlight the high order diffraction spots on the (13×13) grid.

References

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¹ S. Zhou, G.-H. Gweon & A. Lanzara, "Low energy excitations in graphite: The role of dimensionality and lattice defects", *Annals of Physics* **321**, 1730 (2006).

- ² T. Ohta, A. Bostwick, J. L. McChesney, T. Seyller, K. Horn & E. Rotenberg, "Interlayer Interaction and Electronic Screening in Multilayer Graphene Investigated with Angle-Resolved Photoemission Spectroscopy", *Phys. Rev. Lett.* **98**, 206802 (2007).
- ³ I. Gierz, T. Suzuki, R. T. Weitz, D. S. Lee, B. Krauss, C. Riedl, U. Starke, H. Höchst, J. H. Smet, C. R. Ast & K. Kern, "Electronic decoupling of an epitaxial graphene monolayer by gold intercalation", *Phys. Rev. B* 81, 235408 (2010).
- ⁴ A. L. Walter, A. Bostwick, K.-J. Jeon, F. Speck, M. Ostler, T. Seyller, L. Moreschini, Y. J. Chang, M. Polini, R. Asgari, A. H. MacDonald, K. Horn & E. Rotenberg, "Effective screening and the plasmaron bands in graphene", *Phys. Rev. B* 84, 085410 (2011).
- ⁵ A. Bostwick, F. Speck, T. Seyller, K. Horn, M. Polini, R. Asgari, A. H. MacDonald & E. Rotenberg, "Observation of Plasmarons in Quasi-Freestanding Doped Graphene", *Science* **328**, 999 (2010).
- ⁶ B. Lundqvist & V. Samathiyakanit, "Single-particle spectrum of the degenerate electron gas IV. Ground state energy", *Phys. kond. Mat.* 9, 231 (1969).
- ⁷ E. L. Shirley, L. J. Terminello, A. Santoni & F. J. Himpsel, "Brillouin-zone-selection effects in graphite photoelectron angular distributions", *Phys. Rev. B* **51**, 13614 (1995).
- ⁸ J. J. Paggel, W. Theis, K. Horn, C. Jung, C. Hellwig & H. Petersen, "Correlation of surface core levels and structural building blocks for the Si(111)-7×7 reconstruction through high-resolution core-level spectroscopy", *Phys. Rev. B* **50**, 18686–18689 (1994).
- ⁹ D. Stoltz, S. E. Stoltz & L. S. O. Johansson, "A high-resolution core-level photoemission study of the Au/4H-SiC(0001)-(√3 × √3) interface", J. of Phys.: Cond. Matt. **19**, 266006 (2007).
- ¹⁰ J. Ristein, S. Mammadov & T. Seyller, "Origin of Doping in Quasi-Free-Standing Graphene on Silicon Carbide", *Phys. Rev. Lett.* **108**, 246104 (2012).
- ¹¹ S. Hüfner, *Photoelectron Spectroscopy*, 3rd ed., Springer Verlag (2003).
- ¹² C. Riedl, Epitaxial graphene on silicon carbide surfaces: growth, characterization, doping and hydrogen intercalation, Ph.D. thesis, Erlangen-Nürnberg University (2010).
- ¹³ C. Riedl, C. Coletti, T. Iwasaki, A. A. Zakharov & U. Starke, "Quasi-Free-Standing Epitaxial Graphene on SiC Obtained by Hydrogen Intercalation", *Phys. Rev. Lett.* **103**, 246804 (2009).
- ¹⁴ S. Forti, K. V. Emtsev, C. Coletti, A. A. Zakharov, C. Riedl & U. Starke, "Large-area homogeneous quasifree standing epitaxial graphene on SiC(0001): Electronic and structural characterization", *Phys. Rev. B* 84, 125449 (2011).

- ¹⁵ S. Forti, A. Stöhr, A. A. Zakharov, C. Coletti, K. V. Emtsev & U. Starke, "Mini-Dirac cones in the band structure of a copper intercalated epitaxial graphene superlattice", 2D Mater. 3, 035003 (2016).
- ¹⁶ A. B. Preobrajenski, M. L. Ng, A. S. Vinogradov & N. Mårtensson, "Controlling graphene corrugation on lattice-mismatched substrates", *Phys. Rev. B* **78**, 073401 (2008).
- ¹⁷ U. A. Schröder, M. Petrović, T. Gerber, A. J. Martínez-Galera, E. Grånäs, M. A. Arman, C. Herbig, J. Schnadt, M. Kralj, J. Knudsen & T. Michely, "Core level shifts of intercalated graphene", 2D Materials 4, 015013 (2016).
- ¹⁸ B. Premlal, M. Cranney, F. Vonau, D. Aubel, D. Casterman, M. M. De Souza & L. Simon, "Surface intercalation of gold underneath a graphene monolayer on SiC(0001) studied by scanning tunneling microscopy and spectroscopy", *Applied Physics Letters* **94**, 263115 (2009).
- ¹⁹ K. Yagyu, T. Tajiri, A. Kohno, K. Takahashi, H. Tochihara, H. Tomokage & T. Suzuki, "Fabrication of a single layer graphene by copper intercalation on a SiC(0001) surface", *Applied Physics Letters* **104**, 053115 (2014).